

PATENT APPLICATION
IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Docket No: Q77191

Koichi OHTO, et al.

C-I-P Application of
Appln. No.: 10/281,321

Confirmation No.: Unknown

Group Art Unit: Unknown

C-I-P Filed: August 28, 2003

Examiner: Unknown

For: SEMICONDUCTOR DEVICE HAVING SILICON-DIFFUSED METAL WIRING
LAYER AND ITS MANUFACTURING METHOD

PRELIMINARY AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Prior to examination, please amend the above-identified application as follows on the
accompanying pages.

TABLE OF CONTENTS

AMENDMENTS TO THE SPECIFICATION.....	2
REMARKS	3